

Docket No.: 21806-00086-US
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Donna K. Johnson et al.

Application No.: TBA
Div. of U.S. Patent Appl. Serial. No. 09/541,091,
filed March 31, 2000

Art Unit: TBA

Filed: Concurrently Herewith

Examiner: TBA

For: STRUCTURE AND METHOD FOR
FORMATION OF A BLOCKED SILICIDE
RESISTOR

FIRST PRELIMINARY AMENDMENT

MS Non-Fee Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Prior to examination on the merits, please amend the application as follows: